What is claimed is:

1. A gas separation apparatus for separating at least one specific gas from a gas to be treated which contains a plurality of specific gases, said apparatus comprising:

a first separator for separating said gas to be treated into gas groups having different boiling points by distillation separation; and

a second separator for separating specific gases by performing chromatographic separation on at least one gas group separated by said first separator.

- 2. A gas separation apparatus according to claim 1, wherein said second separator chromatographically separates a plurality of specific gases having similar boiling points.
- 3. A gas separation apparatus according to claim 1, wherein said gas to be treated contains PFC gases discharged from a semiconductor manufacturing process as the specific gases and nitrogen as another gas.
  - 4. A gas separation apparatus according to claim 3, wherein said PFC gases contain fluorine compounds having at least one element of C, N, and S as the constituting element.

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- 5. A gas separation apparatus according to claim 3, wherein said PFC gases include at least  $CF_4$  and  $NF_3$ .
- 6. A gas separation apparatus according to claim 5, wherein said  $CF_4$  and  $NF_3$  are separated into the same gas group at said first separator and are separated from each other at said second separator.
- 7. A gas separation apparatus according to claim 4, wherein said  $10^{\circ}$  PFC gases include at least  $C_2F_6$  and  $CHF_3$ .
  - 8. A gas separation apparatus according to claim 7, wherein said  $C_2F_6$  and  $CHF_3$  are separated into the same gas group at said first separator and are separated from each other at said second separator.

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- 9. A gas separation apparatus according to claim 1, wherein said second separator comprises a plurality of chromatographic columns;
- the column into which feed gas flows is sequentially switched among the plurality of chromatographic columns; and the function of each column is sequentially changed.
- 10. A gas separation method for separating at least one specific gas from a gas to be treated containing a plurality of specific

gases, said method comprising the steps of:

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a first separation step for separating said gas to be treated into gas groups having different boiling points by distillation separation; and

- a second separation step for separating the specific gases by performing chromatographic separation on at least one gas groups that is distillation separated at said first separation step.
  - 11. A gas separation method according to claim 10, wherein in said second separation step, a plurality of specific gases having similar boiling points are chromatographically separated.
  - 12. A gas separation method according to claim 10, wherein said gas to be treated contains PFC gases discharged from a semiconductor manufacturing process as the specific gases and nitrogen as another gas.
- 13. A gas separation method according to claim 12, wherein said PFC gases include fluorine compounds having at least one element of C, N, and S as the constituting element.
  - 14. A gas separation method according to claim 13, wherein said PFC gases include at least  $CF_4$  and  $NF_3$ .
- 25 15. A gas separation method according to claim 14, wherein said

 ${\rm CF_4}$  and  ${\rm NF_3}$  are separated into the same gas group at said first separation step and are separated from each other at said second separation step.

- 16. A gas separation method according to claim 13, wherein said PFC gases include at least  $C_2F_6$  and  $CHF_3$ .
- 17. A gas separation method according to claim 16, wherein said  $C_2F_6$  and  $CHF_3$  are separated into the same gas group at said first separation step and are separated from each other at said second separation step.